

ANALYSIS OF IMPURITIES IN ARGON USING COMPACTGC WITH PLASMADETEK-2

Due to Helium shortage, gas suppliers see an increased request for alternative gases. Their clients demand high purity with exact specification for various applications like instrumental use and industrial production. Often PDD (Pulsed Discharge Detector) is used for measuring impurities in bulk gases. But in case of determining the purity of Argon, separation problems arise with this detector because Helium is used as carrier gas and the bulk Argon elutes close to Oxygen. The Plasmadetek-2 from LDetek offers the perfect solution here, since Argon is used as carrier gas, and therefore the bulk peak is not seen at all.

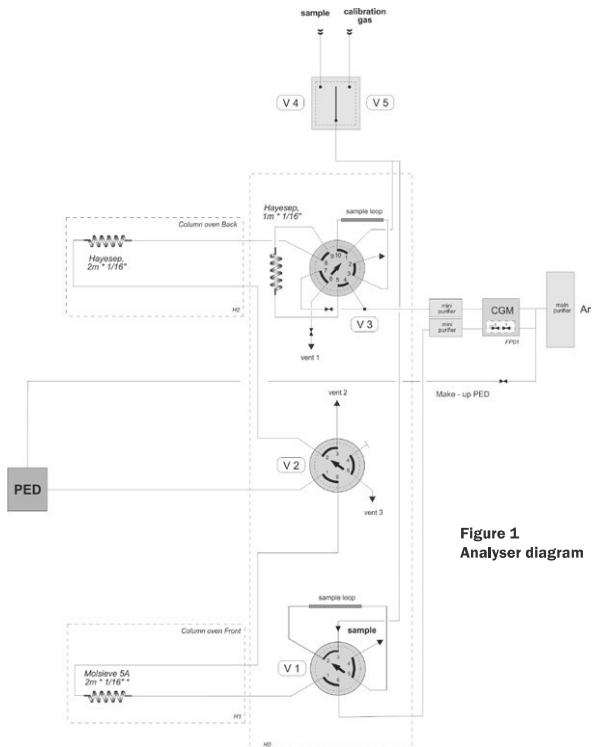


Figure 1
Analyser diagram

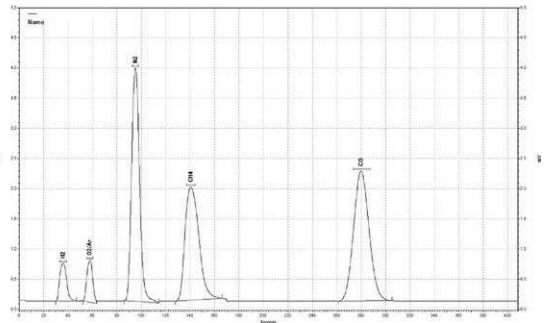


Figure 2
Chromatogram
Molsieve column

Aqilent 35900E Inte...	H2	O2/Ar	N2	CH4	CO
Sample ID	Area	Area	Area	Area	Area
molsieve testFATHel...	203067.00	194281.00	1452795.00	1218724.00	1591571.00
molsieve testFATHel...	202392.00	195591.00	1452917.00	1219249.00	1590896.00
molsieve testFATHel...	205617.00	194085.00	1455726.00	1216440.00	1592798.00
molsieve testFATHel...	204789.00	195496.00	1455690.00	1223070.00	1582777.00
molsieve testFATHel...	205039.00	193859.00	1455817.00	1227535.00	1587183.00
molsieve testFATHel...	205447.00	195147.00	1455831.00	1220549.00	1584348.00
molsieve testFATHel...	205320.00	196256.00	1454897.00	1224674.00	1592919.00
molsieve testFATHel...	203894.00	195299.00	1455741.00	1226357.00	1573995.00
molsieve testFATHel...	206239.00	196406.00	1456723.00	1225968.00	1590468.00
molsieve testFATHel...	205231.00	194874.00	1457012.00	1227555.00	1587986.00
Min:	202392.00	193859.00	1452795.00	1216440.00	1573995.00
Max:	206239.00	196406.00	1457012.00	1227555.00	1592919.00
Mean:	204703.50	195129.40	1455314.90	1223012.10	1587494.10
Std Dev:	1211.05	867.00	1419.98	4022.07	5862.43
%RSD:	0.59	0.44	0.10	0.33	0.37

Figure 3 - Repeatability

Figure 1 shows a two-channel analyser with single Plasma Emission Detector. Valve V1 and Molsieve column analyse H₂, N₂, O₂, CH₄ and CO in Ar. A second channel around valve V3 is present for analysing CH₄, CO₂, N₂O and Ethane in Ar. For analysis of impurities in N₂, a fore-flush column switching option is added to this channel to vent the bulk N₂. Figure 2 shows the Molsieve chromatogram of an 11 ppm calibration standard. Figure 3 demonstrates the obtained repeatability, which is excellent. Valve V2 combines both channels to a single PlasmaDetect-2 detector, which contains up to four sensors for optimal sensitivity for each individual component, see figure 4. Figure 5 shows the integrated analyser using CompactGC^{4.0}.

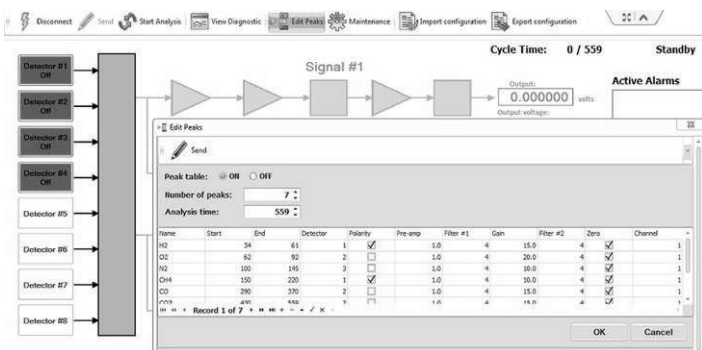


Figure 4 - programming 4 optical sensors in one PlasmaDetect-2 detector



Figure 5 - CompactGC^{4.0}

GLOBAL ANALYSER SOLUTIONS
P.O. Box 2148, 4800 CC Breda, The Netherlands
T: +31 (0)76 5411800 F: +31 (0)842 206757
info@gas-site.com www.gas-site.com